

**REMARKS**

Claims 1-6 and 9-14 are pending in this application. Claims 2-5 were previously withdrawn from consideration. By this Amendment, claims 1 and 10 are amended.

The courtesies extended to Applicant's representative by Examiner Louie at the interview held August 5, 2003, are appreciated. The reasons presented at the interview as warranting favorable action are incorporated into the remarks below and constitute Applicants' record of the interview.

**I. The Claims Define Patentable Subject Matter**

The Office Action rejects claims 1, 6 and 10 under 35 U.S.C. §102(e) over U.S. Patent No. 6,384,529 to Tang et al.; and claims 9 and 11-14 under 35 U.S.C. §103(a) over Tang et al. in view of U.S. Patent No. 6,054,356 to Dawson et al. These rejections are respectfully traversed.

Tang et al. does not teach, disclose or suggest "the bank having a laminated structure with a plurality of layers to form at least a step between the layers, such that the film formation region of the light emitting layers covers the film formation region of the hole injection/transportation layer in order that the electrode avoids contact with the hole injection/transportation layer," as recited in claim 1, and as similarly recited in claim 10.

Instead, Tang et al. merely discloses pillar structure shadow masks for vapor deposition using a vapor stream 83 and 93 directed over an area at a given angle (col. 8, lines 22-29; and Figures 11 and 12). The recited features of a bank having a laminated structure forming at least a step between the layers are not disclosed or suggested by Tang et al.

Dawson et al. does not make up for the deficiencies of Tang et al.

Instead, Dawson et al. relates to a formation of a dielectric, called spin-on glass, "of different viscosities spun on at different speeds," (col. 4, lines 11-21), but does not relate to the recited claim features.

Even if combined, Tang et al. and Dawson et al. do not result in the recited claim features.

For at least these reasons, it is respectfully submitted that claims 1 and 10 are patentable over the applied references. The dependent claims are likewise patentable over the applied references for at least the reasons discussed as well as for the additional features they recite. Applicants respectfully request that the rejections under 35 U.S.C. §103(a) be withdrawn.

In view of the foregoing, it is respectfully submitted that this application is in condition for allowance. Favorable reconsideration and prompt allowance of claims 1-6 and 9-14 are earnestly solicited.

Should the Examiner believe that anything further would be desirable in order to place this application in even better condition for allowance, the Examiner is invited to contact the undersigned at the telephone number set forth below.

Respectfully submitted,



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